



Cite this: *Sustainable Energy Fuels*,  
2019, 3, 1351

## Understanding charge transfer, defects and surface states at hematite photoanodes

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Hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) has been widely investigated as a promising photoanode candidate in photoelectrochemical cells for solar water splitting. Although significant advances have been made to improve bulk charge properties as well as surface catalytic activity for oxygen evolution reaction, it still remains challenging to meet the standards for practical applications. As such, deeper understanding and analysis is necessary to guide efforts to achieve higher activities. This perspective reviews and analyzes the important progress on hematite photoanodes from multiple angles. We highlight the critical role of defect chemistry in terms of bulk properties and surface reaction kinetics. Careful manipulation of the quantity of oxygen vacancies and majority/minority charge carriers is shown to be essential for higher activity. One major type of surface recombination site, which can be readily removed, is identified to be an Fe<sup>2+</sup> species based on multiple photoelectrochemical and spectroscopic observations. Analyzing X-ray absorption spectroscopy and electrochemical energy diagrams, we present a clear picture of water oxidation dynamics at different operating conditions, revealing the relationship between photo-generated holes and surface recombination states. Finally, we conclude that to make hematite photoanodes commercially viable, tuning the minority charge transport properties should be regarded as the priority.

Received 8th March 2019  
Accepted 10th April 2019

DOI: 10.1039/c9se00145j

rsc.li/sustainable-energy

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Hydrogen production from solar water splitting has been an active research field in recent years with great promise to solve energy and environmental problems. It can be carried out in photoelectrochemical (PEC) cells with semiconductor materials, in which hydrogen and oxygen evolve at separate electrodes, hence making it convenient for their collection. The choice of these electrode materials is key to efficient water splitting devices. Of its two electrode reactions, the oxygen evolution reaction (OER) is more challenging than the hydrogen evolution reaction (HER), since the OER involves four electrons to be transferred to produce each O<sub>2</sub> molecule. The OER with poor kinetics competes with much faster charge recombination processes in the semiconductor bulk material and at its surface.<sup>1–3</sup> Hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) has been one of the most extensively investigated photoanode materials due to its relatively small band gap, remarkable stability and great elemental abundancy. However, it also comes with some notorious drawbacks such as low conductivity, small absorption coefficient, poor minority charge mobility (10<sup>-4</sup> cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>), and slow OER kinetics at the semiconductor-liquid junction (SCLJ).<sup>4–6</sup>

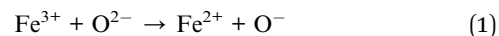
A large number of attempts to tackle these issues, including defect engineering, band engineering and surface treatment, have led to better performance.<sup>7–10</sup> Unfortunately, the underlying reasons for such improvements are not always well understood. For example, using perturbation-modulated techniques such as photoelectrochemical impedance spectroscopy (PEIS) and intensity modulated photocurrent spectroscopy (IMPS), one can obtain the rate constants for surface charge transfer and surface charge recombination.<sup>3,11,12</sup> However, the physical implications of differences in these rate constants with and without modifications of interest, even if calculated correctly, are often not obvious. Band or defect engineering *via* doping, in spite of being one of the most commonly used methods to improve bulk charge transport properties, is also frequently found to significantly change OER kinetics.<sup>7,13–15</sup> Therefore, PEC behavior must be interpreted by more advanced physical characterizations, such as X-ray absorption spectroscopies and infrared spectroscopy (ideally carried out *in situ* or *in operando*).<sup>16,17</sup>

This perspective aims to provide an insight into the effect of defect engineering of hematite photoanodes not only on bulk properties but also on surface reactions, by gathering information from all aspects of PEC research, both computational and experimental. We prove here that direct control of oxygen vacancies and tuning dopant level follow practically the same principle to change the photoresponse of hematite electrodes, while their differences are also discussed. We also show that the presence of defects is highly associated with two types of electronic bands for charge transfer and how they are influenced by overlayers. Moreover, we reveal one possible explanation for the chemical basis of recombination surface states and demonstrate the electrode dynamics at different voltages. Finally, we provide our opinion on future research directions.

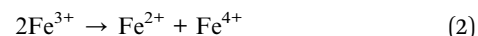
## Charge transfer in hematite

Upon irradiation, there are four types of transitions in hematite as shown in Fig. 1a: (a) single ligand field (LF) transitions; (b)

pair LF transitions; (c) ligand to metal charge transfer (LMCT); (d) metal to metal charge transfer (MMCT). The first two transitions do not generate electron–hole pairs thus they will not be discussed here. Detailed description of them can be found elsewhere.<sup>4,18</sup> The LMCT transition is prevalently recognized as the main, or sometimes, the only source of photocurrent.<sup>19,20</sup> According to the reaction



The excited electron resides at an Fe 3d orbital while the hole resides at an O 2p orbital, which is active for water oxidation. The MMCT indicates an electron transfer from one Fe site to another, resulting in split valences. This process is represented by

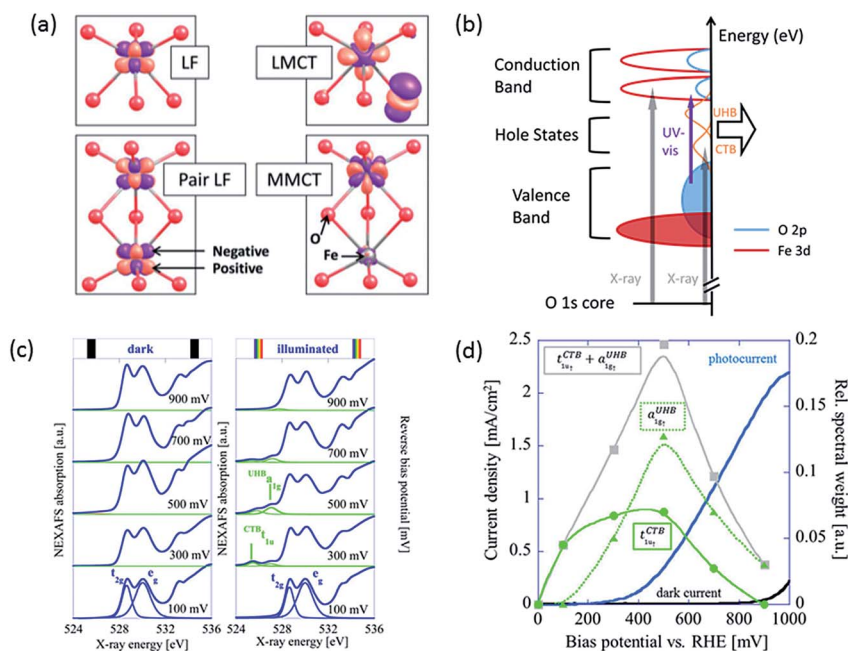


In this case, a hole is generated in an Fe 3d orbital. These two transitions, the LMCT and the MMCT, are also responsible for the electron conduction of hematite; the former is known as O<sup>2-</sup>–Fe<sup>3+</sup> electron hopping and the latter as charge disproportionation.<sup>16,21</sup>

Although MMCT has often been seen as not participating in solar water splitting by some early researchers,<sup>20,22</sup> a more recent work by Braun *et al.* has found evidence that it does account for a significant proportion of photocurrent.<sup>16</sup> They have used near-edge X-ray absorption fine structure (NEXAFS) spectroscopy to study the electronic structure of a hematite photoanode in a PEC cell *in operando*. They discovered that only under illumination did the NEXAFS spectra of the same film contain two pre-edge peaks that represent electron transitions from O 1s core level either to O 2p hole states through charge transfer band ( $t_{1u}^{\text{CTB}}$ ) or to Fe 3d hole states through upper Hubbard band ( $a_{1g}^{\text{UHB}}$ ), in addition to the main edge from transitions to CB levels (Fig. 1b).<sup>16,23</sup> These two types of hole states, potentially active for charge transfer, are separated by about 1.3 eV (Fig. 1c). These peaks become apparent at applied potentials near and above the photocurrent onset potential only when irradiated. According to transient absorption spectroscopy (TAS) results, bulk recombination is found to be ultrafast and a high percentage of holes are lost within 1 ns,<sup>24</sup> so only the rest which migrate to the surface can be detected by NEXAFS. The spectral weight distribution of CTB and UHB for illuminated samples *versus* applied bias is depicted in Fig. 1d. Interestingly, the spectral sum of these two has a peak located near the onset potential, which closely resembles surface capacitance (often referred to as trap states capacitance) measured using PEIS.<sup>7,11,25</sup> The relationship between these two curves will be discussed in later sections.

Since holes from both CTB and UHB can directly contribute to photocurrent, it would be desirable to increase their density of states at PEC operational conditions. Judging from the relative positions and spectral weight of CTB and UHB, it is reasonable to hypothesize that CTB holes influence the low potential performance and even onset potential while UHB





**Fig. 1** (a) Calculated charge density difference isosurfaces (purple) of four types of transitions in hematite upon irradiation: single ligand field (LF) transition, pair LF transition, ligand to metal charge transfer (LMCT) and metal to metal charge transfer (MMCT). Red and grey atoms represent O and Fe atoms. From ref. 4. Reprinted by permission of John Wiley & Sons, Inc. Also adapted with permission from ref. 18. Copyright 2014 American Chemical Society. (b) Schematic diagram of a hematite photoanode showing electronic transitions by UV-visible and X-ray excitation. Orange peaks indicate hole states of CTB and UHB. Reproduced from ref. 23 with permission from The Royal Society of Chemistry. (c) O 1s NEXAFS spectra recorded at bias from 100 to 900 mV in the dark (left) and under illumination (right) conditions. (d) The spectral weight of  $t_{1u}^{CTB}$  (green squares) and  $a_{1g}^{UHB}$  (green triangles) measured by NEXAFS under illumination in relation to photocurrent density of a hematite photoanode. Bias potential can be converted to applied potential vs. RHE by adding flat-band potential of roughly 0.5–0.6 V. Reprinted with permission from ref. 16. Copyright 2014 American Chemical Society.

holes are associated with the high potential performance. As shown in Fig. 1c, the CTB peak is located at 525.8 eV, which is lower than the UHB peak at 527.1 eV. This means less X-ray energy is needed to inject a core electron into CTB than UHB, in turn proving that the energy level of the former is located lower. The CTB holes are found to be more reactive at lower potentials because their reaction is thermodynamically more favorable, as we will expand later. At higher potentials, more contribution must come from UHB holes as a majority of CTB holes have already been participating in OER. More specifically, CTB contribution has dropped to none above 900 mV bias while photocurrent density is still rapidly increasing, meaning UHB contribution is dominating at this stage. Depending on the characteristics of the measured film, the total contribution of UHB holes can be much less if most holes prefer to present themselves in the CTB band. As such, the task of improving photocurrent densities relies on finding the determinants that change the spectral weights of these two bands.

## Oxygen vacancies

Two similar investigations in recent years have examined the effect of oxygen plasma on hematite photoanodes.<sup>26,27</sup> This treatment, in both cases, leads to increased photocurrent densities but higher onset potential too. Hu *et al.* observes a decrease in the concentration of surface Fe<sup>2+</sup> species upon

oxygen-plasma treatment accompanied by an increase of OH<sup>-</sup> species by X-ray photoelectron spectroscopy (XPS).<sup>27</sup> Pyeon *et al.* observes the same but also shows that after a posterior short annealing step the photocurrent is recovered and moreover enhanced (Fig. 2a).<sup>26</sup> Both groups propose that oxygen plasma fills oxygen vacancies and attracts more OH<sup>-</sup> species as the oxidation state of Fe increases. After short-annealing, the newly formed oxygen vacancies are closer to the surface (Fig. 2b). Since both the oxygen vacancies and the CTB/UHB density have a direct influence on the photocurrent curves, we believe there could be a connection between the concentration of oxygen vacancies and the CTB/UHB density.

The link between photoelectrochemistry and the presence of oxygen vacancies can be explained by examining XPS results of hematite before and after annealing treatment.<sup>26</sup> The binding energy of 530.10 eV for lattice oxygen O 1s electrons for untreated hematite is higher than the 529.40 eV for oxygen plasma-treated hematite, then returning to 530.00 eV after short annealing in air at 750 °C. These shifts indicate the possible presence of slightly more positively charged oxygen near oxygen vacancies. Such changes of O 1s binding energy, paired with the increased photocurrent density after oxygen plasma and post-annealing (Fig. 2a), are an indication that upon irradiation and LMCT transition (eqn (1)), transport of O 2p (CTB) holes near the surface is facilitated by virtue of oxygen vacancies. Conversely, the MMCT (eqn (2)) is favored upon irradiation if



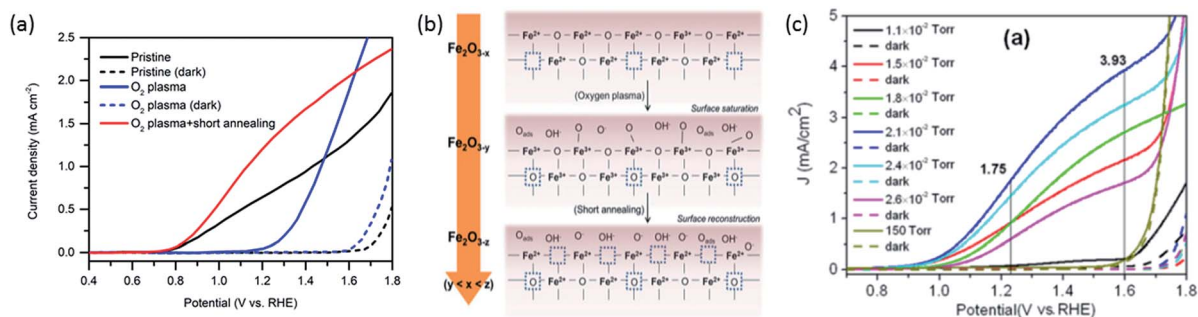
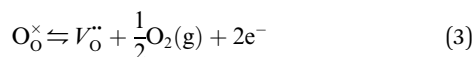


Fig. 2 (a) Photocurrent density curves of pristine (black), oxygen-plasma treated (blue) and short-annealed after oxygen-plasma treated hematite photoanodes (red). (b) Scheme showing filling and reintroduction of oxygen vacancies after oxygen-plasma treatment and re-introduction after short-annealing. Adapted from ref. 26, reproduced with permission. (c) Current density curves of hematite photoanodes after annealing at different partial oxygen pressure. Dashed lines indicate measurements in the dark. Reproduced from ref. 13 with permission from The Royal Society of Chemistry.

Fe<sup>2+</sup> species from pristine hematite have been converted into Fe<sup>3+</sup> by oxygen plasma, reducing the likelihood of recombination of a UHB hole (Fe<sup>4+</sup>) with Fe<sup>2+</sup> (reversed eqn (2)). Although Fe<sup>2+</sup> might also induce recombination with CTB holes (reversed eqn (1)), MMCT is more negatively affected because total Fe concentration is constant and Fe<sup>2+</sup> ions directly suppress the generation of UHB holes (Fe<sup>4+</sup>).

Contrary to oxygen-plasma treatment, annealing in an oxygen deficient environment creates oxygen vacancies, as can be illustrated by the defect equilibrium of the standard oxygen reduction reaction for n-type oxides (Kröger-Vink notation is adopted in this article):<sup>28</sup>



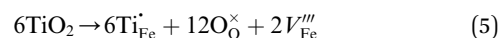
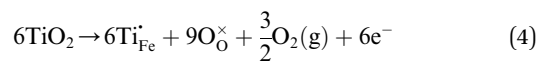
As the partial pressure of oxygen decreases, the reaction proceeds toward the right-hand side, creating more oxygen vacancies. Lower onset potentials have indeed been frequently measured after annealing in low partial O<sub>2</sub> concentration (Fig. 2c) or in N<sub>2</sub>, or after air-plasma treatment, which gives the opposite effect of oxygen plasma treatment. However, the plateau photocurrent densities have also been improved.<sup>9,13,29</sup> It can be noticed in eqn (3) that creating more V<sub>O</sub><sup>••</sup> is accompanied by an increase in the concentration of electrons, leading to higher bulk conductivity. Therefore, plateau photocurrent still increases in spite of less contribution from UHB holes. However, excessive oxygen vacancies are detrimental, as evidenced by lower photocurrent densities.<sup>13,30</sup> This has been associated with lattice distortion and crystallographic phase mixing of α-Fe<sub>2</sub>O<sub>3</sub> and Fe<sub>3</sub>O<sub>4</sub>. A computational study has predicted an optimal concentration of surface oxygen vacancies of 1.26 nm<sup>-2</sup> at (0001) surface, as a result of balancing its opposite effects of overpotential on hydroxyl terminated sites and oxygen terminated sites.<sup>31</sup>

## Cation doping

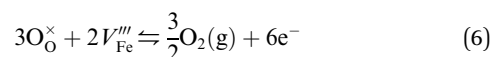
In addition to oxygen vacancies, doping also has an impact on bulk electronic properties as well as on surface kinetics. This

perspective focuses on cation doping of hematite, to which a majority of studies are dedicated. We emphasize aliovalent doping (n-type and p-type) here but isovalent and dual-element doping will also be covered briefly.

One of the most common n-type cation dopants for hematite photoanodes is titanium.<sup>7,13,32–37</sup> Electronic (eqn (4)) and ionic (eqn (5)) compensation are competing processes upon Ti doping:<sup>28</sup>



Each of them is irreversible but the resulting equilibrium obtained by subtracting one from the other can be seen as reversible:



Here we only focus on substitutional rather than interstitial doping since the former was found to be more stable by simulation.<sup>5</sup> The equations above deserve careful examination as they have implications in both bulk electronic properties and surface kinetics. The conductivity of Ti-doped hematite does not necessarily increase unless electronic compensation outweighs ionic compensation.<sup>28</sup> Moreover, simulation by Liao *et al.* has compared the conductivities of several 4-valence cation doped hematite structures and has argued that electrons are more localized at Ti sites, which means they behave like traps.<sup>5</sup> In contrast, dopants such as germanium and silicon form more covalent bonds with oxygen and free electrons occupy the anti-bonding orbitals, which become more mobile. However, we could not find experimental validation in the literature.

The equilibrium of eqn (6) (applicable for other n-type dopants) is influenced by multiple factors including dopant concentration, partial pressure of oxygen during annealing, and annealing temperature.<sup>28</sup> At high dopant levels, ionic



compensation dominates electronic compensation, meaning a maximum of conductivity is only achieved at low dopant concentration. This phenomenon has been studied for Sn doping, where maximal conductance is achieved at 3 at%.<sup>14</sup> Low oxygen pressure annealing is preferred (confirmed by DFT+U simulation) as more electrons can be generated.<sup>32</sup> The transition from electronic compensation to ionic compensation has been theoretically illustrated with a Brower diagram as a function of oxygen partial pressure  $pO_2$ .<sup>38</sup> The authors demonstrate that at high oxygen level, negative charges are predominantly compensated by iron vacancies therefore free electron concentration falls. In the low  $pO_2$  region, this compensation is also present, causing the increase of majority charge carrier concentration to be dependent on the doping density by a power of 1/3. Hence, the authors appeal that researchers should take  $V_{Fe}'''$  compensation into consideration when doping hematite. The roles of  $V_{Fe}'''$  on hematite band structures and for OER have been computationally examined elsewhere but will not be elaborated here.<sup>39,40</sup> It is worth noting that the optimal photocurrent has been achieved at a doping level of Sn different to 3%: 0.7 at% for  $5 \times 10^{-1}$  Torr  $pO_2$  and 0.1 at% for  $5 \times 10^{-5}$  Torr  $pO_2$  annealing.<sup>14</sup> Therefore, doping requires fine tuning to obtain optimal photocurrent. Finally, high annealing temperature (above 700 °C for hematite electrodes in practice) drives eqn (6) to the right-hand side because of an increase in entropy, which means electronic compensation expressed by eqn (4) is more favored. Unintentional doping from diffusion of Sn from the fluorine-doped tin oxide (FTO) conductive support can be introduced to improve conductivity, only if the total dopant concentration is within the peak level. Furthermore, high annealing temperature also has an impact on surface properties, which will be discussed in more detail later.

Due to the Schottky defects equilibrium as shown in eqn (7), iron vacancies created through the ionic compensation upon Ti doping (eqn (5)) inevitably reduce the amount of oxygen vacancies:



Thus, Ti doping is expected to have a similar impact on surface kinetics to oxygen-plasma treatment that reduces

oxygen vacancies. Indeed, it is frequently observed in photocurrent curves of Ti-doped samples (e.g., Fig. 3a) that the plateau photocurrent increases while onset potential also shifts anodically.

The plateau photocurrent is associated with a number of factors described above so the degree of improvements would vary. The onset potential, associated with surface kinetics, is more interesting to investigate. Often it is anodically shifted by 0.1 to 0.2  $V_{RHE}$  for films with n-type dopants, but only when annealed at high temperatures (700–800 °C).<sup>10,15,41</sup> This is in good agreement with the distribution shift between CTB and UHB, and it is additionally proved by the fact that even with the presence of hole scavenger  $Na_2SO_3$ , the onset potential also has a noticeable shift (Fig. 3b and c).<sup>9</sup> For films annealed at relatively lower temperatures, photocurrent is considerably lower or negligible for solution-processed electrodes.<sup>33,41,42</sup> In contrast, films prepared by atmospheric-pressure chemical vapor deposition show appreciable photocurrent at the same annealing temperature.<sup>42</sup> Given this, we believe that the consequences of high temperature annealing are two-fold: (a) enhancing the hematite crystallinity and (b) removing recombination surface states (r-SS). Zandi and Hamann have identified two types of surface states by rapid scan cyclic voltammetry and have shown that r-SS centered near 0.75  $V_{RHE}$  are removed upon 800 °C annealing (Fig. 4a).<sup>43</sup> Notably, a bare hematite photoanode with a record low onset potential of 0.58  $V_{RHE}$  has been fabricated by 10 s of  $H_2$ - $O_2$  flame treatment at 1700 K.<sup>44</sup> Coincidentally, Brillet and co-workers' study on functional annealing gives indirect evidence of r-SS oxidation.<sup>45</sup> When their hematite electrode is calcined in a  $SiO_2$  template to preserve nanoporosity, the onset potential is 160 mV lower than without template, indicating unsuccessful removal of r-SS.

Amongst the n-type dopants, manganese is an exception that negatively shifts onset potential. In spite of an increase of predicted reaction energy (related to overpotential),<sup>46</sup> the surface charge transfer accelerates and charge recombination slows down according to IMPS results.<sup>3</sup> It has been postulated that Mn forms multivalent oxidation states that leads to a low (O–Mn–O) energy barrier for hole transfer.<sup>47</sup> Vibronic superexchange effect is also possibly playing a part, since it has been recently found to enhance electrocatalytic performance of  $La_2NiMnO_6$ .<sup>48</sup>

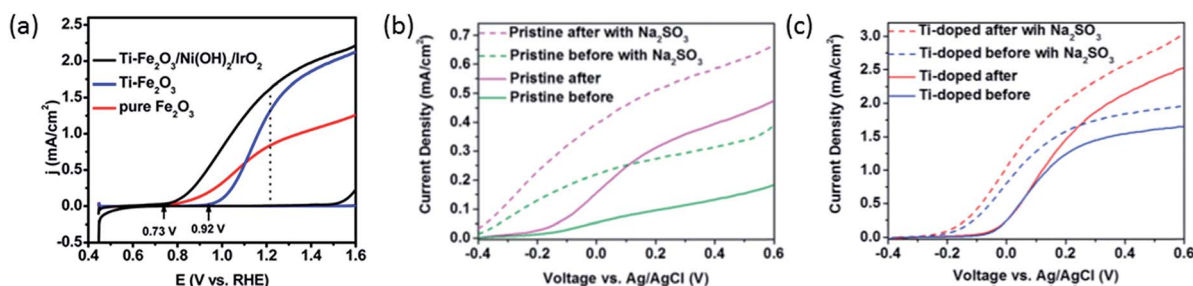
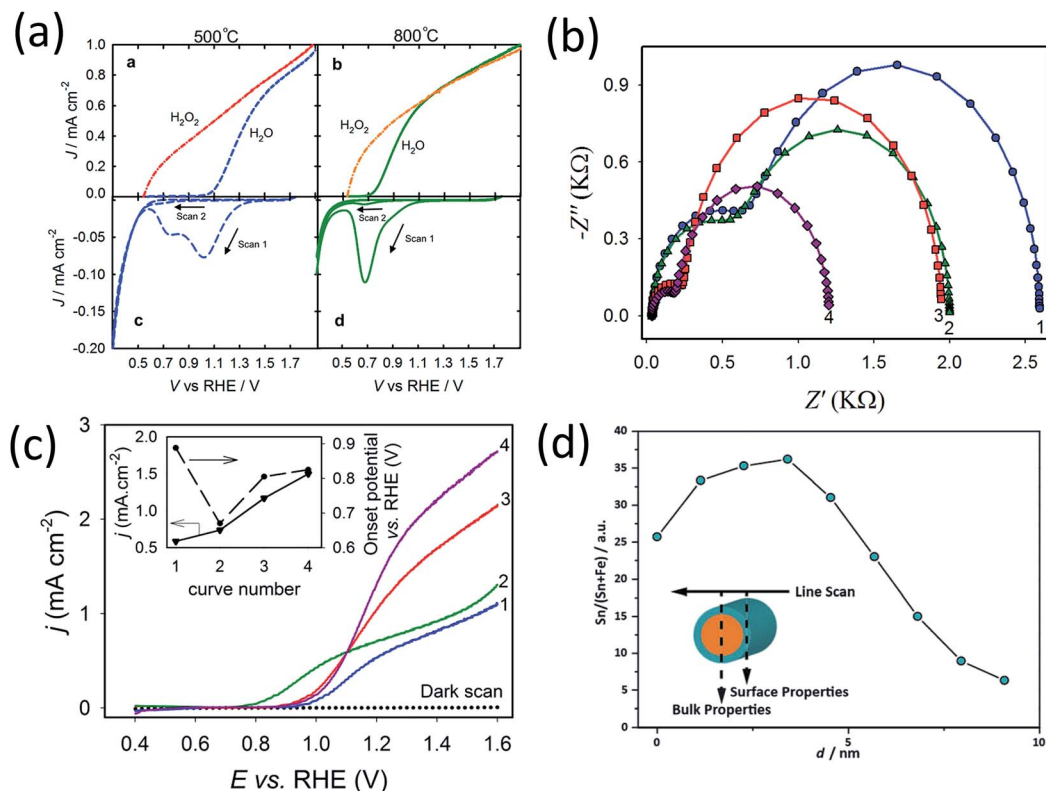


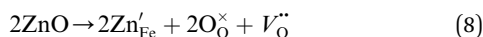
Fig. 3 (a) (Photo)current density curves of pure (red) Ti doped (blue), and Ti doped  $Ni(OH)_2$ - $IrO_2$  coated (black) hematite photoanodes. Reprinted with permission from ref. 10. Copyright 2015 American Chemical Society. (b) Photocurrent density curves of pristine hematite photoanodes before (green) and after (purple)  $N_2$  annealing. (c) Photocurrent density curves of Ti doped hematite photoanodes before (blue) and after (red)  $N_2$  annealing. Dashed lines in (b) and (c) indicate measurements with  $Na_2SO_3$  in the electrolyte. Reproduced from ref. 9 with permission from the PCCP Owner Societies.



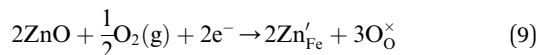


**Fig. 4** (a) Linear sweep voltammograms for hematite electrodes annealed at (top left) 500 °C and (top right) 800 °C in air measured in H<sub>2</sub>O and H<sub>2</sub>O<sub>2</sub>. Cyclic voltammograms scanned at 1 V s<sup>-1</sup> in the dark of the electrodes annealed at 500 °C (bottom left) and 800 °C (bottom right). Reprinted with permission from ref. 69. Copyright 2014 American Chemical Society. (b) Nyquist plots for and (c) photocurrent density curves of (1) pristine hematite, (2) 10.71% Zn, (3) 1.96% Ti, and (4) 1.40% Ti + 5.58% Zn-modified hematite electrodes. Reprinted with permission from ref. 35. Copyright 2014 American Chemical Society. (d) Atomic concentration of Sn as a function of position for a 20% Sn-Fe<sub>2</sub>O<sub>3</sub> photoanode. Reproduced from ref. 50 with permission from the PCCP Owner Societies.

Acceptor-type (p-type) dopants such as Zn and Cu create more oxygen vacancies as a result of the dissolution reaction:<sup>28</sup>



If oxygen is present, it also proceeds *via*



which depletes electrons in n-type  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> and reduces conductivity. When dopant level is sufficiently high, mobile holes will be generated, forming a p-type  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>. A bulk p-type  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> is unsuitable for photoanodes because downward band bending is formed at SCLJ junction and holes tend to move away from the surface. The opposite effects of n-type doping by p-type doping are initially expected. Liao *et al.* has calculated the volcano plot of reaction energy for OER at a hematite (0001) surface doped with a selection of dopants.<sup>46</sup> The dopants were found to alter the stabilities of holes on the active O anions. As a consequence, Co and Ni p-type doping yield lower reaction energies whilst Ti and Si n-type doping yield higher ones. Multiple other experimental and computational works with p-type dopants also support the improvements of surface kinetics.<sup>8,35,49</sup> Although extra V<sub>O</sub><sup>•</sup> introduced by doping indirectly

assist OER, the downside is the drop of bulk conductivity (eqn (3) and (9)). For example, doping of Be at 6% can reduce the plateau photocurrent by nearly 30% at 1.6 V<sub>RHE</sub>,<sup>15</sup> and therefore the dopant concentration should be limited, preferably close to the surface.

It can be seen now that overall improvement of photocurrent cannot be easily achieved by using only one treatment. Although annealing in an oxygen deficient atmosphere seems to be one possibility as we have mentioned, the improvement in plateau photocurrent is often quite limited compared to n-type doping (Fig. 3b and c).<sup>9</sup> Dual-element doping has been attempted by adding a mixture of n-type and p-type dopants. Mirbagheri *et al.* has co-doped Ti and Zn into hematite and characterized films with PEIS.<sup>35</sup> The advantages of each individual doping, *i.e.*, decreased bulk charge transport resistance for Ti-Fe<sub>2</sub>O<sub>3</sub> and decreased surface charge transfer resistance for Zn-Fe<sub>2</sub>O<sub>3</sub>, are both obtained in Ti/Zn-Fe<sub>2</sub>O<sub>3</sub> film at 1.0 V<sub>RHE</sub> (Fig. 4b). The plateau photocurrent exceeds films doped with either Ti or Zn, which can be attributed to released lattice strain (Fig. 4c).<sup>15</sup> Interestingly, its onset potential is maintained at 0.9 V<sub>RHE</sub> as opposed to shifting toward 0.8 V<sub>RHE</sub> for Zn-Fe<sub>2</sub>O<sub>3</sub>. This result implies that dopant or oxygen vacancy concentration is not simply linearly related to onset potential. In another work in which Sn and Be is co-doped, a similar behavior is recorded.



Enhancement in plateau photocurrent density exceeds that of individual doping but onset potential ( $E_{on}$ ) is also unchanged compared with Sn-Fe<sub>2</sub>O<sub>3</sub>.<sup>15</sup> A plausible explanation is that n-type dopants prefer to dominate electrode surface; this has been confirmed in works on Sn and Mn doping, which reveal a gradient of dopant concentration across the film as well as in individual particles (Fig. 4d).<sup>3,50</sup>

A more desirable configuration combining both n-type and p-type doping has been fabricated by Kay *et al.* to produce layered single-junctions (Fig. 5a).<sup>51</sup> Photocurrents improve at both potential ends when hematite is divided into three layers where top layer is doped with Zn and bottom layer with Ti, although  $E_{on}$  is not as low as with individual Zn doping (Fig. 5b). An interesting feature to note here is that  $E_{on}$  drops with increasing thickness of Zn doped layer. This means that p-type doping should not merely be placed at the outermost layer but also somewhat deeper so that O 2p holes transport more easily through slightly positively charged oxygen anions. On the other hand, this penetration depth should not be too high because, as seen before with Ti/Zn-Fe<sub>2</sub>O<sub>3</sub>, bulk co-doping does not reduce  $E_{on}$ . Therefore, control of surface doping of lower valence elements appears to be intricate and challenging.

The less researched dopants are isovalent elements such as Al and Ga. They also show some promise of improving plateau photocurrent density which is attributed to better conductivity due to small polaron migration.<sup>52,53</sup> When doped with Al, there is no apparent change in defect chemistry other than cation replacement and hence no change in  $E_{on}$ .

## Surface states

The origin of surface states as intermediate species or as recombination centers has been under heavy debate. In this perspective, we attempt to combine several existing theories and construct a clearer picture. Durrant group has previously summarized some of their pioneering TAS research and has suggested that recombination centers exist and lie a few hundred millivolts below CB of a Si-Fe<sub>2</sub>O<sub>3</sub> (annealed at 500 °C).<sup>1</sup> Their dynamic model based on TAS is shown in Fig. 6a.<sup>1</sup> At low

potentials, when Fermi level is above r-SS level, electrons are intrinsically trapped. Thus, further trapping becomes more difficult ( $\mu$ s) compared to recombination from VB holes (ps–ns). As applied potential becomes more anodic, band bending depletes these states near the surface, and electron trapping (ps–ns) becomes faster than hole trapping ( $\mu$ s–ms). The population of depleted r-SS is reflected by the bleach signal detected at 580 nm (electronic transition illustrated in Fig. 6b and signal in Fig. 6c). Notably, its intensity follows the square root relationship with applied potential, meaning the r-SS are formed within space charge layer. These states are tentatively assigned to Fe<sup>2+</sup>-V<sub>o</sub> that turn into Fe<sup>3+</sup>-V<sub>o</sub> when become depleted.<sup>1</sup> They have also been previously regarded as chromophores in Fe-TiO<sub>2</sub>.<sup>54</sup> We have found further evidence in the literature from recent years supporting this assignment, as we shall illustrate below.

The positive signal above 650 nm on TAS results indicates the population and lifetime of holes (electronic transition illustrated in Fig. 6b and signal in Fig. 6d).<sup>1,26</sup> Its intensity at short time domains doubles after oxygen-plasma treatment, likely due to the reduction in the quantity of oxygen vacancies, which are ultrafast recombination centers.<sup>26</sup> This is supported by a simulation demonstrating that oxygen vacancies are even faster charge recombination centers than direct VB–CB recombination by 10 and 30 times for charged and neutral forms, respectively.<sup>55</sup> The timescale (ps–ns) of electron trapping from CB to r-SS measured by another work of Durrant group<sup>24</sup> is also computationally supported by Zhou *et al.*<sup>55</sup> Consequently, oxygen vacancies are very likely to be an integral component of r-SS.

The other part of r-SS, Fe<sup>2+</sup>, can be more confidently confirmed with several approaches. Hu *et al.* has found a numeric match between the density of states and surface Fe<sup>2+</sup> species concentration, thus confirming that r-SS are highly associated with Fe<sup>2+</sup>.<sup>56</sup> As previously mentioned, high temperature annealing is capable of removing this type of r-SS (Fe<sup>2+</sup>-V<sub>o</sub>), presumably by oxidation of Fe<sup>2+</sup> to Fe<sup>3+</sup>. For a 500 °C treated sample, the empty form of electron traps can live up to 10 ms indicated by 580 nm bleach signals, whereas the signal disappears for a 750 °C treated sample for a wide range of applied potentials.<sup>26</sup> Although a feature emerges at 1.5 V<sub>RHE</sub>, the

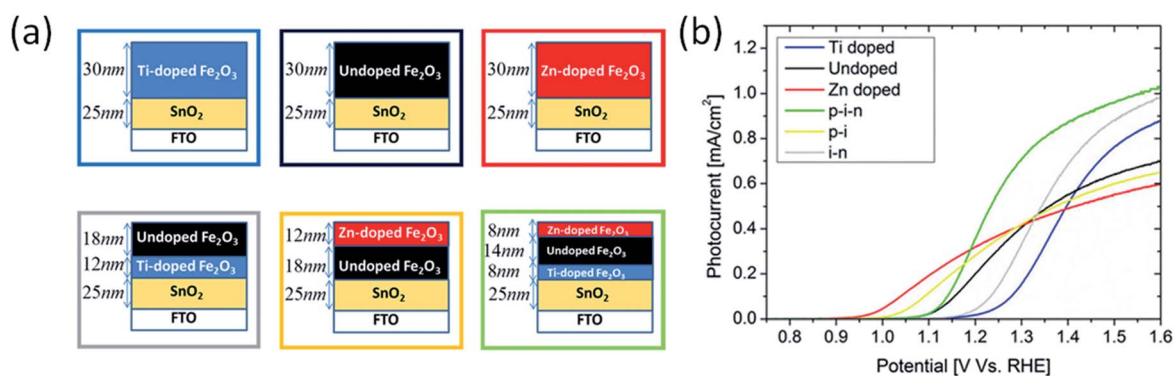


Fig. 5 (a) homogeneously Ti-doped ( $\sim 1$  cation%) hematite film (blue), undoped hematite film (black), homogeneously Zn-doped ( $\sim 1$  cation%) hematite film (red), heterogeneously doped i–n stack (grey) heterogeneously doped p–i stack (yellow), and heterogeneously doped p–i–n stack (green). (b) Photocurrent density curves of films in (a), following color scheme of boxes in (a). Reprinted with permission from ref. 51. Copyright 2016 American Chemical Society.



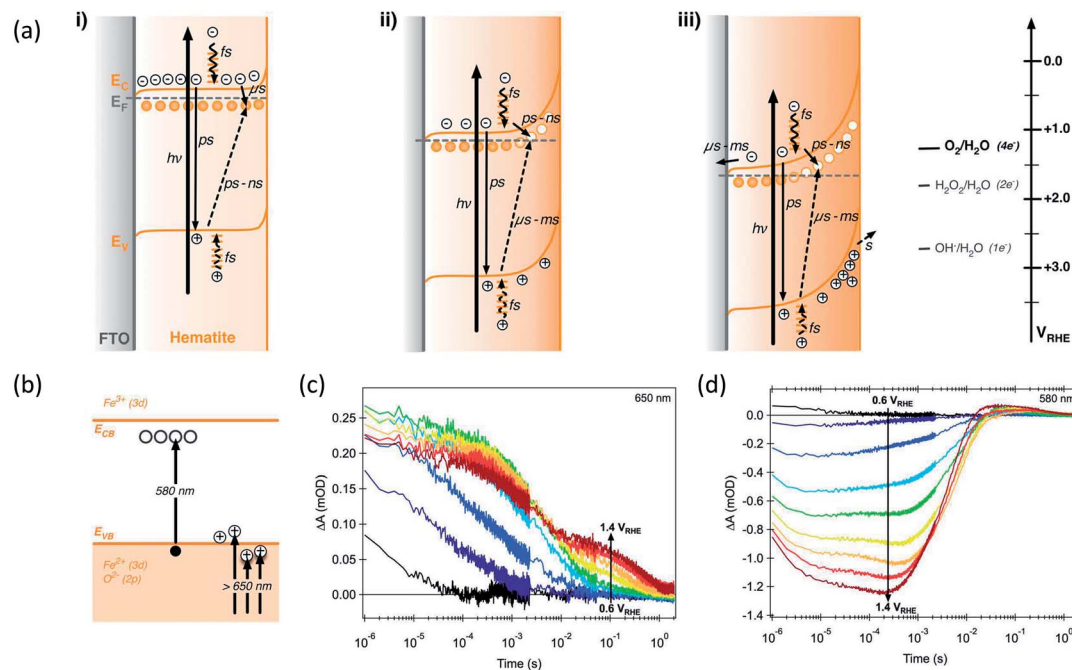


Fig. 6 Energy diagrams and processes involving photogenerated charge carriers for a hematite photoanode at various applied potentials at (i) 0.5, (ii) 1.1 and (iii) 1.6  $V_{\text{RHE}}$ . Circles indicate electron trap states. (b) Scheme of electronic transitions responsible for the Vis-NIR transient absorption spectra of hematite photoanodes. Reproduced from ref. 1 with permission from The Royal Society of Chemistry. (c) Transient absorption decay dynamics of 650 nm. (d) Transient absorption decay dynamics of 580 nm. Reproduced from ref. 65 with permission from The Royal Society of Chemistry.

timescale is 100  $\mu\text{s}$  as opposed to 10 ms, so it must originate from recombination surface states of a different nature.<sup>26</sup> Hence, high temperature treatment can successfully reduce the population of  $\text{Fe}^{2+}$ , not to mention the improvement in crystallinity. Here, we should note that although high temperature introduces more oxygen vacancies, they are not as influential as  $\text{Fe}^{2+}$ , which act as redox centers. Although oxidation potential of  $\text{Fe}^{2+}$  at hematite surface is undefined, we notice that the standard redox potential of  $\text{Fe}^{3+}/\text{Fe}^{2+}$  (0.77  $V_{\text{RHE}}$ ) is located several hundred millivolts below CB edge (0.3–0.4  $V_{\text{RHE}}$ ) and extremely close to that observed by Zandi *et al.* (0.75  $V_{\text{RHE}}$ ).<sup>43</sup> Moreover, the computationally predicted position of  $V_{\text{O}}$  at 400 mV below CB by Zhou *et al.*<sup>55</sup> suggests possible interaction between  $V_{\text{O}}$  and  $\text{Fe}^{2+}$  due to their close proximity in energy alignment.

The spectral weight distribution of CTB, interestingly, follows a square root dependence on bias potential, in line with the development of 580 nm signal in TAS.<sup>1</sup> It suggests strengthened band bending with applied potential, while r-SS is consequently being depleted (Fig. 6a). However, it is hard to judge which of the two types of holes is performing the depletion. Although we believe it is more likely to be the UHB holes due to their closer proximity in energy and the absence of its spectral weight at low bias, possibility of recombination between CTB and r-SS cannot be ruled out. This question could be readily answered by NEXAFS measurements on the same samples after r-SS removal by high temperature annealing, although it remains unexplored in literature.

The surface states directly detected by TAS suggest that they are not only at the top surface layer but extend into the bulk as

the space charge region builds up as a function of applied bias. However, since the space charge region is only a few nanometers wide, these states can be still termed as “surface states”. This point has been previously mentioned by Barroso *et al.*<sup>42</sup>

Knowing the chemical origin of r-SS, we now focus on the crucial different effects that annealing and cation doping can have on the presence of oxygen vacancies and the relative amounts of CTB and UHB holes. N-type dopants (for example, Ti, Si and Sn) increase the concentration of nearby  $\text{Fe}^{2+}$ .<sup>15,57,58</sup> On the other hand, filling oxygen vacancies by oxygen plasma treatment or likewise reduces  $\text{Fe}^{2+}$  concentration.<sup>27</sup> Although the increase of  $\text{Fe}^{2+}$  is known to assist polaron hopping and subsequently electrical conductivity,<sup>39</sup> its existence near the surface (forming r-SS) would quench both CTB and UHB holes. An amorphous layer of  $\text{Fe}_x\text{Sn}_{1-x}\text{O}_4$  of 1–2 nm reduces the charge injection efficiency below *ca.* 1.1  $V_{\text{RHE}}$ .<sup>60</sup> But more efficient charge injection was recorded at higher potentials, where  $\text{Fe}^{2+}$  (r-SS) species are oxidized by the bias, so that UHB can be effectively used for OER. Such response is a firm proof of our theory on the role of UHB and CTB holes as there are no bulk effects involved in this case. Conversely, p-type doping would reduce  $\text{Fe}^{2+}$  concentration, therefore expected to enhance both CTB and UHB hole fluxes. At lower potentials, in particular, the removal of r-SS allows for a much higher generation of effective CTB holes for water oxidation. Hence, lowered onset potential is often observed.<sup>8,35,61</sup> Direct evidence can be found in a work where an Ni-doped overlayer of  $\text{Ni}_x\text{Fe}_{2-x}\text{O}_3$  cathodically shifts onset potential of hematite by 100 mV while surprisingly enhancing photocurrent density by 2–3 fold.<sup>61</sup> Creating a p-type  $\alpha\text{-Fe}_2\text{O}_3$  layer by 3% Mg



doping on the top 20 nm layer has reduced onset potential by more than 200 mV, while slightly raising plateau saturation too.<sup>8</sup> Although the establishment of internal fields by homojunctions is claimed responsible for the improvement in the latter case, we believe changes in the contribution of holes are also playing a role here since uniform bulk p-type doping sometimes produces similar effects (Fig. 4c).<sup>35</sup>

In contrast to r-SS, the forms and chemistry of intermediate surface states (i-SS) that mediate OER are far more complicated and are still under heavy debate. Multiple oxidation states of Fe, such as IV, V, and even VI have been proposed to be present during OER, some of which have been experimentally observed.<sup>17,62–64</sup> It is also possible for a variety of OER mechanisms to occur simultaneously with either single or multiple oxidation states of Fe.

Regardless of the nature of i-SS, a procedural scheme can be demonstrated to show the fate of CTB and UHB holes in

hematite photoanodes when r-SS are present. Fig. 7 shows a schematic illustration of mixed energy diagrams of hematite photoanodes with CTB (red) and UHB (blue) and with the presence of r-SS at three applied potentials (0.55, 0.9, and 1.3  $V_{RHE}$ ). The X-ray energy scale is also displayed, where peak edge is simply set to be at half-height (528.2 eV), matching the CB minimum at electrode surface. A few basic assumptions were made in Fig. 7 for a typical hematite photoanode: (a) a band gap of 2.2 eV;<sup>65</sup> (b) CB minimum at 0.3  $V_{RHE}$ ,<sup>66</sup> (c) a flat band potential of 0.5  $V_{RHE}$ ,<sup>67</sup> and (d) r-SS at 0.75  $V_{RHE}$ . As shown in Fig. 7a at  $E_F = 0.55 V_{RHE}$ , which is close to the flat-band potential, the holes at the surface are very limited because they come from only a short diffusion layer of about 2 nm into the surface with little assistance from band bending. Holes can easily recombine with r-SS since they lie below Fermi level and will be immediately refilled with electrons (Fig. 7a). As potential is swept anodically, r-SS near the surface begin to be

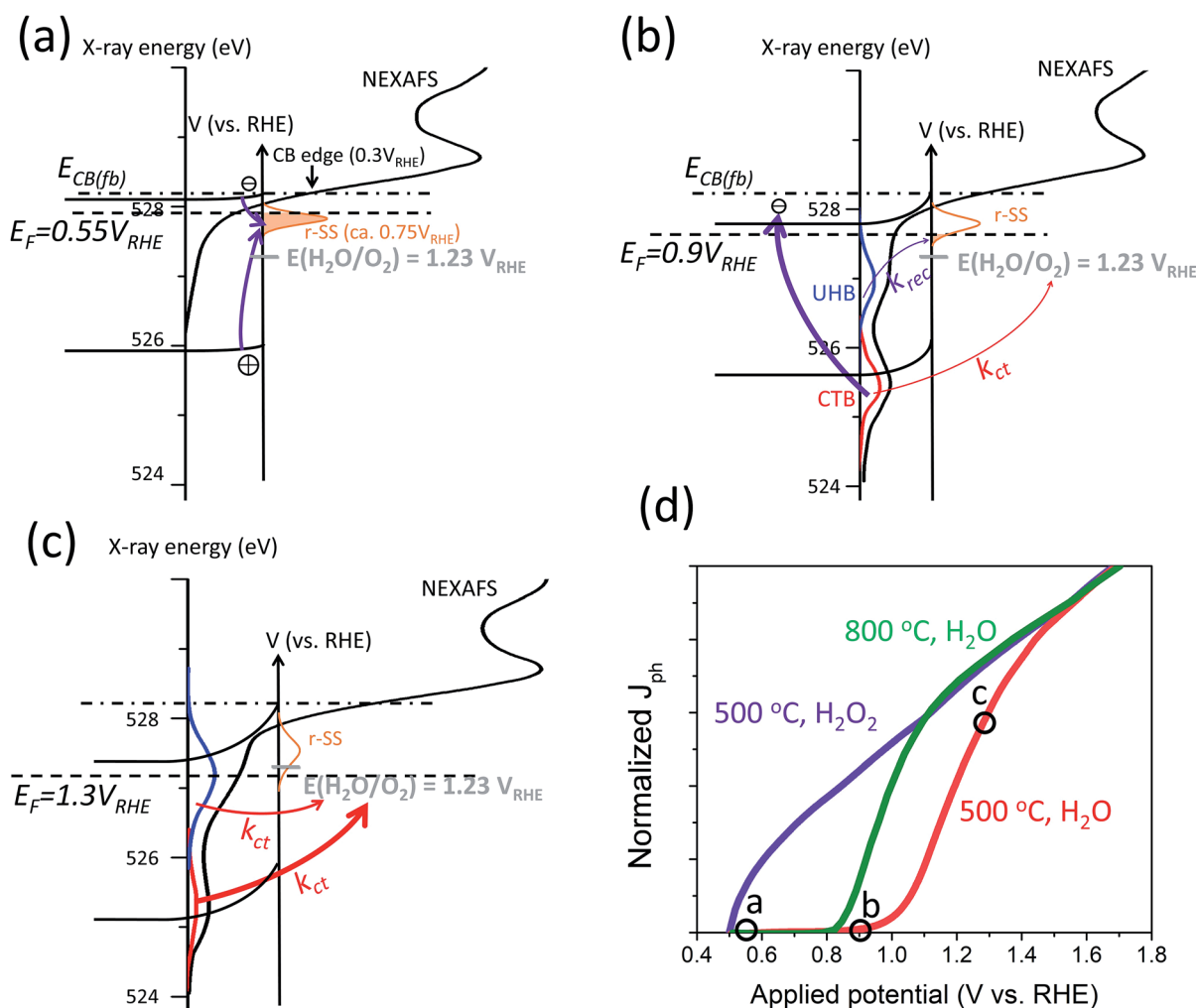


Fig. 7 Schematic illustration of mixed energy diagrams of hematite photoanodes at operating conditions with CTB (red) and UHB (blue) and with the presence of r-SS at applied potentials of (a) 0.55, (b) 0.9, and (c) 1.3  $V_{RHE}$ . Arrows of different thicknesses indicate relative rates of important charge transfer and surface recombination processes. Purple arrows indicate surface recombination processes; red arrows indicate charge transfer processes. Grey dashes indicate OER potential of 1.23  $V_{RHE}$ . NEXAFS data obtained from ref. 16. (d) Normalized typical  $J-V$  responses of a hematite photoanode calcined at 500 °C in  $H_2O$  (red) and  $H_2O_2$  (purple) and calcined at 800 °C in  $H_2O$  (green). The position of the scenarios presented in (a), (b) and (c) are marked out in the  $J-V$  red curve of (d).



depleted primarily by UHB holes because of smaller energy differences (marked by thin purple arrow in Fig. 7b). Dare-Edwards and co-workers has pointed out that VB holes arrive at surface in  $\text{Fe}^{3+}$  orbitals; these  $\text{Fe}^{3+}$  have negligible rate constants for water oxidation.<sup>67</sup> Meanwhile, CTB holes do not generate photocurrent as well because of their low surface concentration. They mostly undergo surface recombination (illustrated by a thick purple arrow, Fig. 7b). Therefore, even if r-SS are removed by high temperature annealing, photocurrent onset still cannot approach the same value in  $\text{H}_2\text{O}_2$  (*c.f.* green curve, Fig. 7d). When potential increases further, r-SS near the surface soon become fully depleted above  $0.9 V_{\text{RHE}}$  according to constant 650 nm signal intensity below  $10^{-3}$  s from TAS results shown in Fig. 6c.<sup>1</sup> At this point, CTB holes reach a critical concentration, leading to photocurrent onset as holes arriving in O 2p have a facile faradaic route to  $\text{O}_2$  formation (thin red arrow in Fig. 7b).<sup>67</sup> A small amount of UHB holes also exist but do not yet contribute to photocurrent.<sup>16,68</sup> As bias is further swept anodically, rapid water splitting kinetics is capable of dissipating the CTB (O 2p) accumulated holes, reducing its spectral weight observed with NEXAFS (Fig. 7c). Likewise, this trend appears for UHB holes but approximately 0.1–0.2 V more positive (Fig. 7d). Note that the peak intensity is much higher than that of CTB, which is possibly due to the lower overpotential of UHB holes compared to  $1.23 V_{\text{RHE}}$ . Information about surface OER kinetics of excessive long-lived holes can be extracted from the second decay phase of 650 nm signal (Fig. 6c).<sup>1</sup> Fig. 7d shows the  $J$ - $V$  responses of a typical hematite electrode (produced at  $500^\circ\text{C}$ ) marking out the points where each scenario projects to. The presence of r-SS is partly responsible for the strong contrast between  $J$ - $V$  curves measured in  $\text{H}_2\text{O}$  and  $\text{H}_2\text{O}_2$ .

A better understanding of the photoelectrochemistry of a hematite photoanode in operation from spectroscopic findings allows for more rational investigation of PEIS outcomes. It is apparent that the overall spectral weight curve from NEXAFS closely resembles surface capacitance measured by PEIS. We believe that the surface capacitance is a reflection of CTB and UHB holes, in the form of both intermediate species and possibly positively charged r-SS but further investigation on this topic remains worthwhile.

At present, PEIS data is commonly interpreted following different models. In one model, charge transfer takes place directly from VB holes and surface states only account for recombination (Fig. 8a). In an alternative model, both charge transfer and recombination take place *via* the same surface states (Fig. 8b). Deciding which model is more appropriate depends on the relative quantities of i-SS and r-SS as well as applied potential. Equivalent circuits of these two models are mathematically indistinguishable, and calculation of rate constants by either method produces same values.<sup>68</sup> However, Klahr *et al.* points out that the latter model is more physically meaningful because a peak maximum corresponds to a dip in charge transfer resistance.<sup>25</sup> We agree with this statement but moreover, we believe that the other model is possibly not suitable at all for hematite on the basis of more experimental evidence, as follows. For hematite films calcined at

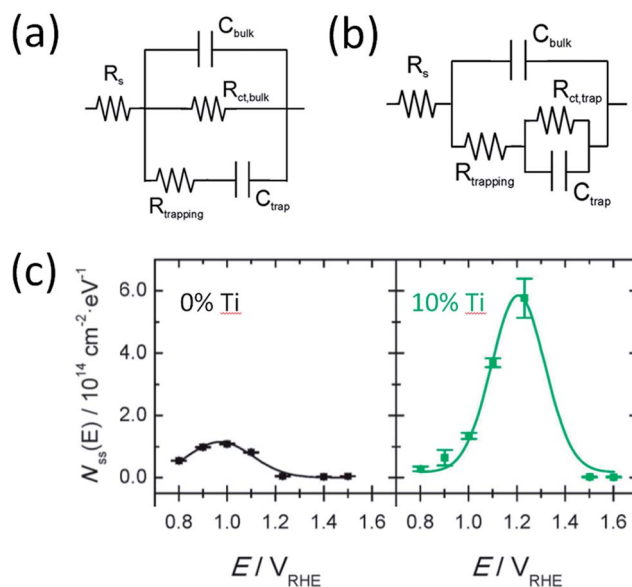


Fig. 8 Two types of equivalent circuit from PEIS to represent hematite photoanodes under illumination. Model in (a) suggests charge transfer through valence band and recombination through trap states. Model (b) suggests charge transfer and recombination both occur through surface trap states. Reprinted with permission from ref. 25. Copyright 2012 American Chemical Society. (c) Density of surface states calculated from surface capacitance measured using PEIS with model (b) for pristine and Ti doped hematite photoanodes. Reproduced from ref. 7 with permission from The Royal Society of Chemistry.

intermediate temperatures (around  $500^\circ\text{C}$ ), surface capacitance  $C_{\text{ss}}$  peaks were not observed to start from 0.6 V, which would be the case if charged r-SS were oxidized by CTB holes according to NEXAFS spectral weights. Instead,  $C_{\text{ss}}$  only starts near the onset potential of 0.9 to 1 V.<sup>2,25</sup> In contrast, for  $800^\circ\text{C}$  calcined samples, density of surface states  $N_{\text{ss}}$  (derived directly from  $C_{\text{ss}}$ ) does rise from 0.6 V as extrapolated from Fig. 8c,<sup>7</sup> which demonstrates the appearance of CTB holes for OER. This is also in line with the intense peak centered at 0.75 V in Fig. 4a(d) recorded using CV in the dark.<sup>69</sup> Furthermore, Ti-doped films heated at  $800^\circ\text{C}$  that are known to have more  $\text{Fe}^{2+}$  show depressed  $C_{\text{ss}}$  at low potentials (Fig. 8c), which further proves that PEIS does not detect r-SS. Note at high potentials,  $C_{\text{ss}}$  increases substantially, peaking at 0.2 V above non-doped samples, indicating a much higher maximum surface concentration of UHB.

Knowing the physical origin of r-SS, we are able to summarize the mixed effects of oxygen vacancies in hematite photoanodes. First, they discharge the surrounding oxygen atoms to yield more  $\text{O}^-$  species that are beneficial for charge transfer of CTB holes. Second, they act as fast recombination sites either on their own or coupled with  $\text{Fe}^{2+}$ . Consequently, although the distribution of surface capacitance is located more cathodically, its intensity is lower than when there are less oxygen vacancies, as evidenced again in Fig. 8c. This trade-off is probably the source of difficulties when trying to improve the activity of a hematite photoanode, especially at low applied potentials. Apart from these roles already discussed, oxygen vacancies may



also reduce the adsorption energy of H<sub>2</sub>O molecules, and subsequently reduce OER overpotential and Tafel slope, as observed for NiCo<sub>2</sub>O<sub>4</sub>.<sup>39,70</sup>

## Deposition of overlayers

It would be also helpful to consider the effect of overlayers on surface states, which is still under heavy debate. As Barroso has mentioned in an early report, there is some ambiguity regarding the definition of “surface state”.<sup>71</sup> A majority of publications use this term for states that exist only at the top molecular layer, whereas Fe<sup>2+</sup>-V<sub>o</sub> can spread deeper into the surface, for example, in the space charge region. This notion clarified, the roles of surface layers including co-catalysts, compact non-catalytic layers, and surface doped layers become clearer.

The deposition of an overlayer can partly or entirely cover the defects of the outermost hematite, including a fraction of Fe<sup>2+</sup>-V<sub>o</sub> and other possible types of surface states. Here, we emphasize the difference between a co-catalyst (*e.g.*, transition metal oxides and (oxy)hydroxides) and a compact non-catalytic layer (*e.g.*, Ga<sub>2</sub>O<sub>3</sub> and Al<sub>2</sub>O<sub>3</sub>). It has often been reported that the plateau photocurrent density drops with a Ga<sub>2</sub>O<sub>3</sub> overlayer.<sup>53,72</sup> A possible justification is that when Ga<sub>2</sub>O<sub>3</sub> covers Fe<sup>2+</sup> sites, it influences O 2p (CTB) and UHB holes differently: (a) more O 2p (CTB) holes will be transferred to O atoms of Ga<sub>2</sub>O<sub>3</sub> rather than used for oxidizing r-SS, improving the low potential performance; (b) as more Fe sites are covered, charge transfer through UHB holes is inhibited. In the case of cobalt-based co-catalysts such as CoPi, the increase in O 2p (CTB) hole flux toward Co sites does not lead to acceleration in catalysis.<sup>2,71</sup> Instead, recombination is retarded, which is associated with the low electrocatalytic activity of Co by itself compared with Fe sites, as reported by Boettcher group.<sup>73</sup> For instance, the measured turnover frequency was 0.035 s<sup>-1</sup> for Co<sub>3</sub>O<sub>4</sub> at η = 325 mV,<sup>74</sup> while 12 s<sup>-1</sup> for CoFeO<sub>x</sub> at η = 350 mV.<sup>75</sup> Our group has recently reported a moderate improvement of charge transfer rate with CoFeO<sub>x</sub> coating only when the loading is extremely low;<sup>41</sup> and we have observed the same for thin NiFeO<sub>x</sub> coating. Thus, it can be said that the only part of the co-catalyst that assists OER is the layer where it connects to the hematite structure.

In contrast, if Co or Ni atoms are dispersed into hematite near the surface and interact with Fe atoms inside hematite structure, a far more significant benefit will be harnessed, in addition to reducing the number of Fe<sup>2+</sup>. This comparison of surface doping and deposition has been made clear by Cheng *et al.* with Co;<sup>61</sup> the same prediction was also made through simulation in the same year by Liao *et al.*<sup>46</sup> Unfortunately, this approach has been considerably outnumbered in the literature by surface deposition methods to reduce onset potential.

## Charge generation and transport

As described in Fig. 1b, single and double ligand field transitions do not generate charge pairs upon irradiation. For this reason, Kennedy and Frese's calculation of the absorption coefficient based on *J-V* curves was found lower than the real value.<sup>20</sup> A few more theoretical and experimental approaches

confirmed this major efficiency loss mechanism that hampers high photogeneration yields.<sup>76,77</sup> This is indeed another major curtailment to the expected photocurrent output. The low photogeneration yield has a strong wavelength dependence, which has been associated to polaronic trapping<sup>23,78</sup> but different interpretations coexist.<sup>79</sup> Therefore, better understanding of charge carrier dynamics must be first attained before research moves on to minimizing these unwanted transitions.

Currently, the best hematite-based photoanodes reported in the literature can only output photocurrents around 5 mA cm<sup>-2</sup> at 1.23 V<sub>RHE</sub> under 1-sun illumination (AM1.5G), which are much lower than the theoretical limit of 12.6 mA cm<sup>-2</sup>.<sup>80-83</sup> It has frequently been reported that while charge injection efficiency can reach 90–100% with strong bias, charge separation efficiency is far lower regardless of applied potential.<sup>9,60</sup> Therefore, we and other researchers<sup>3</sup> believe that to further improve the performance of hematite as photoanodes and make them industrially viable, research should be mainly aiming at enhancing the bulk charge transport properties rather than surface OER kinetics, since researchers have established multiple tools to achieve this, *e.g.*, by surface doping or controlled annealing.

To increase the electronic transport, or conductivity, the most obvious way is n-type doping. In Engel and Tuller's work, the conductivity of 1% Ti-doped hematite shows around four orders of magnitude higher conductivity at room temperature if calcined in air, which even reaches nine orders of magnitude higher in low O<sub>2</sub> concentration (0.1% and 0.01%).<sup>38</sup> In another work with the same doping level, photocurrent density for OER is indeed substantially increased. However, it only increases by less than three times at 1.23 V<sub>RHE</sub> in the presence of 0.5 M H<sub>2</sub>O<sub>2</sub>, which indicates that the hole flux increases by no more than one order of magnitude. The authors also confirmed that the surface hole concentration for water splitting reaction increases by only about four times using IMPS. The most probable reason for such low improvements in hole current as opposed to significant improvements in conductivity is the strengthened band bending due to the higher concentration of free electrons.

For hematite, conductivity along crystal orientation (110) has been reported to be four orders of magnitude higher than along (001).<sup>84</sup> However, these two orientations offer the same hole flux,<sup>85</sup> presumably because there is no difference in free electron density, giving a similar chance of bulk recombination.

Improving the hole (minority carrier) transport, *i.e.*, mobility and lifetime, is a much more significant issue. For example, Peter *et al.* discovered that in stark contrast to the Gartner model, recombination is an apparent hindrance even within the space charge region.<sup>86</sup> Applied bias has been recognized as a way to retard ultrafast recombination in the bulk hematite, but not much progress has been made by means of film fabrication.<sup>24</sup> Another notable measure to enhance minority carrier mobility is by thermal energy, which can be achieved by concentrated solar illumination. Moreover, higher light intensity can also increase photovoltage and fill factor.<sup>87</sup> Future research in this direction would be highly meaningful.



## Conclusion and outlook

In summary, we have discussed the presence in hematite of charge transfer band (CTB) O 2p holes and upper Hubbard band (UHB) Fe 3d holes upon illumination and critically analyzed the role of oxygen vacancies and doping, as well as the origin of recombination surface states. Our main conclusion is that introducing oxygen vacancies at surfaces, by controlled annealing or p-type doping, gives rise to more positively charged oxygen anions, which assist the transport of CTB holes; whereas reducing the amount of oxygen vacancies, by oxygen-plasma treatment or n-type doping, decreases the degree of Fe–O hybridization and facilitates charge transfer *via* UHB.<sup>26</sup> Additionally, concentration of near-surface Fe<sup>2+</sup> species is influenced differently upon annealing or doping. Among the methodologies covered here, the most promising way is to n-type dope in the bulk plus p-type dope near the surface. We then define one type of recombination surface states to be Fe<sup>2+</sup>–V<sub>o</sub> that mainly consumes CTB holes and prevents early onset potential. These states are strongly affected by heating conditions: a short high temperature can readily remove them. On the basis of TAS findings, integration of NEXAFS results into photoelectrochemistry has led us to a far more clarified energy picture at hematite electrodes. Our theory is in agreement with a majority of theoretical and experimental data in the literature. The impacts of high temperature treatment, overlayer deposition and surface doping have also been discussed. We note that the key limiting factor of hematite as photoanodes is its poor hole transport properties instead of electronic transport (conductivity). If this issue is overcome, and given its remarkable stability, hematite would undoubtedly secure its progress toward commercial PEC application.

Finally, this perspective has deepened the understanding of the PEC performance of hematite photoanodes by various surface or bulk modifications and provided a useful guide to more efficient photoanodes with other semiconductors for solar water splitting. More importantly, this methodology of interdisciplinary literature review has rarely been applied in materials science, but would be valuable in other fields to gain novel and original understanding from present knowledge.

## Conflicts of interest

The authors declare no conflicts of interest.

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